## VERSION SHOWING AMENDMENTS TO THE CLAIMS

This listing replaces all prior listings of the claims.

## IN THE CLAIMS

Amend the claims as follows:

- 1 (Currently amended). A method for patterning an unpatterned organic layer comprising a layer-forming substance (3; 13), for use in particular of organic circuits, characterized by the method comprising:
- pressing applying a patterning device means (2; 12) at a predetermined, elevated temperature and at a predetermined pressure to into contact points on the organic layer (3; 13), the patterning means making contact with the organic layer (3; 13), the layer-forming substance of the organic layer retreating from the contact points in response to the applied pressure and elevated temperature to thereby form depressions and/or holes in the organic layer but not piercing it, and the organic layer (3; 13) being permanently patterned and pierced after the pressing-on.
- 2 (Currently amended). The method as claimed in claim 1<sub>\_</sub>, characterized in that including choosing a the substance is chosen which forms the organic layer (3; 13) in such a way that the organic layer (3; 13) is opened permanently under the applying action of the patterning device means (2; 12).
- 3 (Currently amended). The method as claimed in claim 1 including effecting one of the

preceding claims, characterized in that the <u>applying step</u> pressing in is effected over a predetermined time period.

- 4 (Currently amended). The method as claimed in <u>claim 1</u> one of the preceding <u>claims</u>, <u>characterized including supporting in that</u> the patterning means (2;12) are <u>device arranged</u> on a planar carrier (1; 10, 11)
- 5 (Currently amended). The method as claimed in <u>claim 1 including forming one of the</u> preceding claims, characterized in that the patterned organic layer (3; 13) has depressions <u>and/or holes (6; 16)</u> in accordance with <u>a pattern on</u> the patterning <u>device</u> means (2; 12).
- 6 (Currently amended). The method as claimed in claim 5, characterized in that including providing a further layer (4) is provided, which is covered by the organic layer (3; 13), the depressions and/or holes (6; 16) essentially extending continuously to as far as the further layer (4).
- 7 (Currently amended). The method as claimed in claim 5 or 6, characterized in that wherein the including forming the depressions and/or holes (6; 16) are suitable for forming plated-through holes.

8 (Currently amended). A device for patterning <u>an</u> organic layers, in particular of <u>comprising a layer-forming substance for use in an</u> organic circuits, <u>the device</u> <u>comprising:</u>characterized by patterning means (2; 12)

## a support; and

a patterning arrangement coupled to the support and having predetermined dimensions, the patterning arrangement -means, being arranged for being heated to at a predetermined [[,]] elevated temperature and for receiving at a predetermined pressure [[,]] for contacting after making contact with the layer-forming substance of the organic layer at the elevated temperature and predetermined pressure (3; 13), patterning the latter permanently because the organic layer (3; 13), after contact has been made, retreats at the contact points in such a way that to displace the layer-forming substance such that depressions and/or holes are formed in the layer-forming substance, which depressions and/or holes essentially correspond to the dimensions of the patterning arrangement arise there.

9 (Currently amended). The device as claimed in claim 8 wherein, characterized in that a the layer-forming substance is chosen which forms the organic layer (3; 13) in such a way that the organic layer (3;13) is opened permanently under the action of the patterning arrangement means (2; 12).

- 10 (Currently amended). The device as claimed in claim 8 or claim 9, characterized in that wherein the patterning support comprises means are arranged on a planar carrier (1).
- 11 (Currently amended). The device as claimed in claim 8 or claim 9, characterized in that wherein the support is patterning means are arranged on a planar, flexible carrier (11), which is in turn arranged circumferentially on a roll-type carrier (10).
- 12 (Currently amended). The device as claimed in claim 11 wherein the roll-type carrier has a circumferential speed, the device including, characterized by a conveying device (18) adapted for conveying the organic layer essentially synchronously with the a circumferential speed of the roll-type carrier (10).
- 13 (Currently amended). The device as claimed in <u>claim 8 one of the preceding claims</u>
  8 to 13, characterized by <u>including</u> a <u>further</u> device (18) adapted for pressing the
  patterning <u>arrangement</u> <u>means</u> into the organic layer at the predetermined pressure.
- 14 (Currently amended). The device as claimed in <u>claim 8 one of the preceding claims</u>
  8 to 13, characterized by <u>including a further device</u> (17) adapted for heating the
  patterning <u>arrangement means</u> to the predetermined temperature.